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SPECTROSCOPIC ENLIGHTENING OF THE LOCAL STRUCTURE OF VO_x ACTIVE SITES IN CATALYSTS FOR THE ODH OF PROPANE

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Abstract

Site isolation of V active sites has been often correlated to catalytic performance for the oxidative dehydrogenation (ODH) of propane to propylene. In particular, catalyst selectivity seems favoured by high V dispersion. The latter property is hardly attainable by traditional preparation methods, especially by impregnation except at very low V loading, which however may lead to a too high surface exposure of the acidic sites of the support. In this paper, the effect of the preparation procedure on catalyst properties has been investigated, particularly considering catalysts prepared by flame pyrolysis, a synthesis method which induced a very high V dispersion also at relatively high vanadium loading. Transmission electron microscopy also allowed us to assess V oxide dispersion depending on both the support type and the preparation method. Furthermore, the local structure of the V active sites has been deeply investigated by X-ray Absorption Spectroscopy, allowing us to propose a possible structure of the active sites.

The average oxidation state of surface V species was then studied by X-ray Photoelectron Spectroscopy (XPS), showing a role of V oxidation state on catalyst selectivity. The catalytic performance has been interpreted on the basis of V species and catalyst acidity (as measured by IR spectroscopy), another fundamental parameter that in turn results to be correlated with V dispersion on different supports. More selective catalysts were indeed characterized by the presence of weaker Brønsted acidic sites.

Keywords: Oxidative dehydrogenation (ODH) of propane; Propylene production; V-based catalysts; X-ray absorption.

1 - Introduction

Light olefins are important building blocks for polymers and intermediates industry ¹. The need for light olefins is progressively growing, with a higher rate for propene, leading to the necessity of alternative production routes ². Direct dehydrogenation can be an interesting alternative when low value feedstock is available. However, it is an endothermal reaction needing a high energy input, it is equilibrium controlled and the catalyst may be easily deactivated by coking. The oxidative dehydrogenation (ODH) of light paraffins to the corresponding olefins has been proposed as a means to overcome all these limitations. In addition, oxygen limits severe catalyst coking ³. In spite of the considerable attention paid to this process and testified by a certain number of patents (see *e.g.* ^{4,5} and references therein), the ODH technology can be hardly considered mature and it has not yet reached industrial application due to selectivity issues. Indeed, oxygen should ideally consume H₂, but paraffins and (most of all) olefins combustion is an unavoidable side reaction, which drives products yield below acceptable limits.

Among the possible catalyst formulations, V-based catalysts proved active and selective for the ODH of propane ². Different possible reaction pathways have been proposed ^{6,7}, depending on the polymerisation degree of V species on the surface.

According to DFT calculations, a one-electron reduction seems more likely for isolated V⁵⁺ species, leading to V⁴⁺, which is readily reoxidised by O₂. A two-electron reduction mechanism is also proposed for dimeric V species ⁷ and it is not excluded also for the monomeric ones ⁶ and it is assumed as the preferred reaction pathway by some authors ⁸. A strong dependence on the support has been evidenced, the V⁴⁺/V³⁺ ratio in the reduced catalyst depending on the possible delocalisation of unpaired electrons and on the amount of oxygen vacancies of the support (especially for TiO₂) ⁹, though discrepancies are found in the literature on this point. Indeed, according to Koranne *et al.* ¹⁰ a preferential V⁵⁺ \rightarrow V⁴⁺

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reduction would occur when using Al_2O_3 as support, while a 70% $V^{5+} \rightarrow V^{3+}$ reduction has been predicted for silica supported samples. By contrast, other researchers ^{11,12} report that the latter reduction path holds for VO_x/TiO_2 catalysts, whereas that leading to V^{4+} is active for Al_2O_3 and SiO_2 based samples. Furthermore, the vanadyl oxygen does not seem responsible for the first oxidative formation of propene, but it is likely involved in its nonselective complete oxidation ¹³. This may explain the reason why stronger V=O bonds observed for some V-Si-O systems with respect to V-Al-O ones were correlated to a higher selectivity to propene ¹⁴⁻¹⁶.

A detailed assessment of the nature of V-containing species can be done by coupling several characterisation techniques, among which Raman, FT-IR, UV-Vis spectroscopies, X-ray Diffraction (XRD) and Temperature Programmed Reduction (TPR), the latter technique assessing a mean oxidation state of Vⁿ⁺ species. Four types of V-containing species have been identified in supported VO_x catalysts: (1) isolated surface VO₄ species containing one terminal V=O bond and three bridging V-O-support bonds, (2) polymeric surface VO₄ species containing one terminal V=O bond and three bridging V-O-support bonds, (2) polymeric support bonds, (3) crystalline V₂O₅ and (4) compounds forming mixed oxides with the support, usually upon calcination at high temperatures (*e.g.* Zr(V₂O₇)₂, AlVO₄, V_xTi_{1-x}O₂, NbVO₅, Mg₃(VO₄)₂, Mg₂V₂O₇)^{8,17}.

At low V loading, isolated monovanadate species are usually present, which progressively oligomerise and polymerise up to a monolayer with increasing V concentration; beyond this point V₂O₅ segregation occurs. Different V loadings and V surface densities corresponding to monolayer completion characterise each support ^{8,18-20}. For example, the extent of polymerisation follows the trend $Al_2O_3 > ZrO_2 >> SiO_2$ ⁸. Isolated VO_x species can be found on SiO₂ up to *ca*. 2 V/nm² surface density, whereas alumina- or titania-supported samples showed higher surface density (7-8 V/nm²), corresponding to polymeric vanadyl species. With the latter supports, it was difficult to attain high V dispersion, unless by

excessively decreasing the V loading, with detrimental effects on both activity and selectivity ⁸.

High reaction rates for the ODH of C_2 - C_4 paraffins are found with polymerised vanadate species, up to the formation of a VO_x monolayer, while lower activity and selectivity are usually associated with the presence of bulk V_2O_5 ²¹⁻²³. Furthermore, when the support has a strong Lewis acidity ²⁴ the formation of a compact VO_x monolayer completely covering the support acid sites is desired to improve selectivity.

To sum up, a deepening of the correlation between V-site properties and catalyst selectivity would be welcome. Indeed, attempts to increase V dispersion by common preparation procedures often ended in the enhancement of different factors such as acidity, support exposure and activity, etc.

A detailed assessment of V local structure may help in elucidating activity and selectivity issues, above all if coupled with a detailed investigation on catalyst acidity. Therefore, the present investigation aims at defining the active site structure of VO_x/SiO₂ and VO_x/Al₂O₃ catalysts characterised by variable metal loading and prepared by different techniques. X-Ray Absorption Spectroscopy (XAS) has been used to assess the local environment of the active metal and the results, compared with X-ray diffraction, Micro-Raman, Fourier Transform Infra-Red (FT-IR) spectroscopies and Electron Paramagnetic Resonance (EPR) data, helped in interpreting the catalytic performance. Transmission Electron Microscopy (TEM) allowed assessing V dispersion and location on the support surface. A tentative structure of the active sites is also proposed. Finally, a correlation between V dispersion, oxidation state and acidity on different supports has been also introduced.

2 - Experimental

2.1 - Sample Preparation

A detailed description of the flame pyrolysis (FP) preparation procedure and of the effect of the main operating parameters on catalyst properties can be found elsewhere $^{25-28}$. A 0.1-0.2 M solution of precursors (with respect to the nominal oxide composition) in organic solvent was fed to FP the burner (4.4 cm³/min), together with 5 L/min of oxygen (SIAD, purity >99.95%). The cross section area of the burner was adjusted so to have a pressure drop of 0.4 bar across the nozzle. The catalyst powder so produced was collected by means of a 10 kV electrostatic precipitator 25,29 .

Al(NO₃)₃*9H₂O, tetra-ethyl-orthosilicate (TEOS) and V oxi-acetyl-acetonate were used as precursors ¹⁴⁻¹⁶. The solvent was a 1:1 (vol/vol) mixture of ethanol and 1-octanol for the alumina based samples and 1:1 (vol/vol) mixture of ethanol and propionic acid for the silica based ones.

Comparative samples have been prepared by impregnation of FP-prepared SiO₂ and Al₂O₃ supports from a NH₄VO₃ solution (samples V10Si-i and V10Al-i). The catalysts were then dried and calcined at 700 °C in air flow.

A different preparation route has also been used, namely co-gel formation from TEOS and ammonium vanadate 30 , achieving a V₂O₅ content of 6.7 wt% (sample VAG1) and 15 wt% (sample VAG3).

Samples composition is reported in Table 1, where silica and alumina supported catalysts are represented by Si and Al in the sample code, respectively.

2.2 – Samples Characterisation

Specific surface area (BET) was determined by N₂ adsorption/desorption at -196 °C on a Micromeritics ASAP2010 instrument, after outgassing overnight at 300 °C (Table 1). XRD analysis was carried out on a Philips PW3020 powder diffractometer, by using the Ni-filtered Cu K α radiation (λ =1.5418 Å). The diffractograms obtained were compared with literature data for phase recognition ³¹.

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X-ray absorption spectra were collected at the GILDA beamline in the ESRF facility (Grenoble, France). *Ca.* 50 mg of sample were carefully grinded and mixed with cellulose powder, then pressed to obtain a thin wafer. Samples of V_2O_5 and AIVO₄ were used as reference. The spectra have been collected in transmission mode, using ion chambers as detectors and a Si(311) double crystal monochromator. The energy calibration has been made by measuring the spectrum of a reference V foil, simultaneously with the sample by using a third ion chamber. The EXAFS data analysis has been made by means of the iXAFS package ^{32,33}. For the XANES analysis, the spectra have been pre-edge fitted by a straight line, and normalised to unit edge jump.

Scanning Electron Microscopy (SEM) observations have been carried out using a Leo Stereoscan 440 microscope equipped with an EDX probe (Oxford Link System, Ge detector) and with a back scattering detector (Centaurus). The catalyst powder has been carefully distributed on the analysis stub and sputtered with carbon in order to observe its morphology and to perform element analysis.

Trasmission Electron Microscopy (TEM) investigations have been carried out using a JEOL JEM 2010 equipped with an EDX analysis probe (Oxford Link System, Si(Li) detector). The catalysts samples have been carefully dispersed in isopropanol using a ultrasound bath to break-up the aggregates and then a sample drop has been deposited on a Lacey carbon grid.

XPS (X-ray photoelectron spectroscopy) spectra were recorded on a PHI 5000 Versa Probe apparatus using a band-pass energy of 187.85 eV, 45° take off angle and a 100.0 µm diameter X-ray spot size. Curve-fits were performed by means of Multipak 9.0 software, after Shirley background subtraction.

IR spectra were collected on a FT-IR spectrophotometer (Equinox 55, Bruker), equipped with a MCT (Mercury Cadmium Telluride) cryodetector. For IR measurements, powder samples were pressed into thin self-supporting wafers (density of about 10 mg cm⁻

²) and outgassed at 150 °C in a standard vacuum frame (residual pressure below 10^{-3} mbar) by using IR cells equipped with KBr windows. The outgassing temperature was chosen in order to preserve Brønsted acidic sites that are removed at higher outgassing temperatures ¹⁴. NH₃ adsorption was run at room temperature on samples outgassed at 150 °C by dosing increasing amounts of ammonia (partial pressure in the 0.00-30.0 mbar range) and evacuating to remove the reversible fraction of the adsorbate.

2.3 – Catalytic activity tests

Catalytic activity was measured by means of a continuous, quartz tubular reactor (i.d.= 7 mm) heated by a furnace. The catalyst (0.90 mL, 0.5-0.6 g, 0.425-to-0.600 mm particle size) was activated prior to each run in 20 cm³/min flowing air, while increasing temperature by 10 °C/min up to 550 °C, then kept for 1 h. Every sample was tested under aerobic (co-feed) or anaerobic conditions. In the former case, the flow rates of the reactants were 11 cm³/min of C₃H₈ (20 mol%) + 11 cm³/min of O₂ (20 mol%) + 28 cm³/min of He + 4 cm³/min of N₂ (60 mol% inert). For the "anaerobic mode" flow rates were 6 cm³/min of C₃H₈ (22 mol%) + 19 cm³/min of He + 2 cm³/min of N₂. The contact time was 1 s for the former and 2 s for the latter testing mode, respectively, in both cases operating as an integral reactor. The outflowing gas was analysed by means of a micro-GC (Agilent 3000A), equipped with a TCD detector, Plot-Q, OV-1 and MS-5A columns for a complete detection of the effluent products. In addition to propane, propylene, CO and CO₂, products quantification included H₂, light alkanes and alkenes, acetic and acrylic acids.

The catalyst was diluted with inert steatite particles and bed temperature was measured by means of an axial thermocouple ($\Delta T_{max} = 7 \,^{\circ}C$ in co-feed mode, $\Delta T_{max} = 5 \,^{\circ}C$ during testing under anaerobic conditions and subsequent re-oxidation). Mass transfer was not limiting the kinetics of the reaction, as assessed during the determination of the reaction rates at

different temperature under aerobic conditions (at low propane conversion). The activation energy resulted around 120 kJ/mol for V/AI samples ¹⁵.

3 – Results and discussion

3.1 Survey of previous results

As for the FP-prepared samples, the XRD patterns of silica supported samples were always amorphous (Table 1). V₂O₅ reflections appeared only at high V loading (> 28 wt%)^{14,16}. On the contrary, either δ - or η -Al₂O₃ was detected in the alumina supported samples, in which the occurrence of V₂O₅ was always observed even at the lowest V loading ^{15,16}. These results were also confirmed by Micro-Raman spectroscopy ¹⁴, which evidenced the absence of V₂O₅ in V10Si sample, the spectrum of which was only characterised by two weak bands at 1027 and 512 cm⁻¹, ascribable to isolated V=O species ³⁴. In the case of Alsupported samples ¹⁵, Raman spectra always evidenced the presence of V₂O₅, its content increasing with V loading. However, with V10Al sample also bands attributed to VO_x and isolated V=O species were detected. The latter were absent with sample V10Al-i, prepared by impregnation, which resulted to be much more similar to sample V50Al.

Finally, electron paramagnetic resonance evidenced ferromagnetic domains constituted by agglomerated V(IV) sites in V10AI-i and V10Si-i samples prepared by impregnation and absent in the corresponding FP ones, further confirming the higher V dispersion in the latter catalysts ¹⁴⁻¹⁶.

All these evidences induced the conclusion of a much higher V dispersion of the FPprepared samples, of course decreasing with raising V loading, with respect to those prepared by impregnation, at similar V concentration. This reflected on catalyst performance ¹⁴⁻¹⁶, showing a higher selectivity (at isoconversion) for sample V10Si with

respect to its homologue prepared by impregnation (V10Si-i), especially when operating under anaerobic conditions. Similar conclusions, though less evident, may be drawn for sample V10AI when compared with V10AI-i.

This intriguing statement has been here verified by comparing some FP-prepared samples with similar ones prepared by co-gelation, a method which should also lead to high V dispersion, and with other samples prepared by V impregnation of FP-prepared supports.

3.2 – SEM-TEM analysis

SEM pictures evidenced more uniform and smaller particles for SiO₂ than for Al₂O₃ samples prepared by FP (Fig. 1). This is connected to the precursors solubility and to the preparation procedure. Propionic acid was used for the preparation by FP of the silica based samples, whereas alcohols were necessary to dissolve the alumina precursor, as detailed in the Experimental section. As already reported elsewhere ^{27,28}, ethanol, and in general alcohols, is not the best choice for this synthetic procedure due to too high volatility, though sometimes forced by solubility issues. Too fast solvent evaporation may indeed lead to uneven particle size distribution.

EDX analysis confirmed a rather uniform V distribution in every sample, notwithstanding a better homogeneity for the silica based samples, with respect to alumina supported ones. Selected TEM pictures are reported in Fig. 2: sample V10Si showed a rather amorphous appearance, in accordance with XRD, without any evidence of phase segregation. At increasing V loading, V₂O₅ aggregates became evident (Fig. 2*b-d*), with a characteristic rod like shape and well defined crystal planes separation. A similar picture was obtained with sample V50AI, though V₂O₅ rods resulted to be much more interacting with the support, since they were grown on it (Fig. 2*e*). Such results were confirmed by TEM-EDX

maps (Fig. 3). In particular, V was homogeneously dispersed in sample V10Si (Fig. 3*a*), whereas aggregates were visible on the shell of V10AI particles (Fig. 3*b*). Electron microscopy data thus show a different V distribution depending on its loading and on the support. A higher surface interaction between V and AI appears, accompanied by a lower dispersion degree.

3.3 - XPS analysis

Fig. 4 reports XPS spectra in the O 1s (a) and V 2p BE regions (b). The O 1s spectra reported in Fig. 4*a* present different features, depending on both V loading and support type. According to literature, the O1s peak is seen at 533 \pm 0.5 eV in silica and at 530 \pm 0.5 eV in V₂O₅ ³⁵: with V28Si sample, the main peak is seen at 533.1 eV, indicating the presence of oxygen atoms bonded to silicon atoms ³⁵. With the same sample, a minor component at lower BE values is also observed, assigned to O atoms interacting with vanadium. The latter assignment is confirmed by the fact that at higher V loading (V50Si sample) the main peak is seen at 530.5 eV, a BE value corresponding to surface V₂O₅, in agreement with previous Raman studies ¹⁴. With the impregnated sample (V10Si-i), a (minor) component at 530.5 eV is also observed, its lower intensity being due to the smaller vanadium content, along with a main band peaking at 532.7 eV, due to oxygen atoms related to Si. With V10Si, the peak of oxygen in silica (533eV) and V₂O₅ (530eV), thus confirming the better vanadium dispersion in the latter sample.

Interpretation of XPS of Al₂O₃-supported samples may be complicated by the fact that the O1s peak is at 531 \pm 0.5 eV in Al-O bonds and at 533 \pm 0.5 eV for Al-OH groups ³⁶, so it is hardly distinguishable from of oxygen in vanadia. Features of the O1s XP spectra of both V10Al and V10Al-i are similar to that of V50Si, indicating the presence of oxygen atoms 11

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ascribed to a separate V₂O₅ phase, along with some oxygen atoms related to AI, confirming that it was not possible to reach a good dispersion of vanadium on Al₂O₃, even at a low V loading. This is probably due to the nature of the alumina matrix, that is less "pliable" with respect to silica and it is not able to accommodate vanadium atoms with a high dispersion. The high pliability of the Si-O-Si bond is well known and it is responsible, for instance, of the variety of silica polymorphs, *i.e.* amorphous or in several crystalline phases ³⁷. Fig. 4*b* reports the corresponding XP spectra in the V2p BE region: at higher BE, the features of V 2p 1/₂ are observed and will not be addressed further, so the focus will be on the main peak due to the V 2p 3/2 transition. The sample V10Si shows a signal at higher BE values with respect to the other samples, that is assigned to the presence of hydrated V⁵⁺ species (V-OH groups), that proved to be very abundant in this sample based on previous IR studies ¹⁴.

Results of the corresponding curve-fittings are reported in Table 2. With all the V-Si samples the presence of V³⁺ (*ca.* 516 eV), V⁴⁺ (*ca.* 517 V) and V⁵⁺ (*ca.* 518 eV) was detected. Interestingly, V10Si-i sample contains a higher amount of V³⁺ species with respect to the samples prepared by FP, probably due to the lower vanadium dispersion reached by impregnation. This fact probably explains the different catalytic performance of the latter sample, as compared to those prepared by FP (*vide infra*). Although fully oxidised samples were used for XPS analysis, some reduction may in principle occur to surface vanadium oxide under high vacuum, though unlikely at r.t. In any case the comparison above reported among average surface oxidation states of different catalysts, analysed under the same experimental conditions, may be seen as an index of the average oxygen availability (or vanadium oxide reducibility), which may be correlated with catalyst activity and selectivity.

3.4 XAS analysis

The XANES spectra and the corresponding derivatives of all the samples are reported in Fig. 5.

The XANES spectrum of V_2O_5 is characterised by a typical three peak manifold between 5480 and 5529 eV. The same structure was found for almost all the samples, thus labelled V_2O_5 -like, with three exceptions: *i*) sample V10Si, for which the XANES manifold is almost identical to that of AIVO₄ (called AIVO₄-like); *ii*) samples V10AI and V28Si, which showed a somehow intermediate shape. In addition, the energy edge position is affected by the so called "chemical shift", the edge shifting to lower energies by decreasing the oxidation state of the photoabsorber. For sample V10Si (AIVO₄-like), the presence of two distinct edges is apparent in both the XANES and in the derivative, indicating thus the occurrence of V in two distinct oxidation states. Similar evidence, though to a lesser extent, is found also for sample V28Si.

These results are also in line with the previously summarised findings, confirming the higher dispersion of VO_x species in the FP prepared samples with respect to samples with the same V loading, prepared by impregnation (samples V10Si-i and V10Al-i).

In principle, co-precipitation may be a preparation method more similar to FP than impregnation, starting in every case from a homogeneous mixture of V and Si (or Al) precursors. This leads to an intimate contact between both precursors, with active phase incorporation into the support matrix. Nevertheless, when comparing sample VAG3 with V10Si, vanadia agglomerates were observed with the former, still present even when halving the V loading (sample VAG1).

The higher V dispersion attainable with the FP technique may be ascribed to the flash calcination at high temperature. This quenches the system in a metastable structure, where V remains finely incorporated into the support matrix as in a mixed oxide. Such situation is not easily allowed during the final calcination step of the traditional preparation

routes, such as co-gelation, which leads to V segregation and aggregation on the catalyst surface even at relatively low V loading ¹⁴⁻¹⁶.

The local structures around each sample, as obtained by the EXAFS fittings, are summarised in Tables 3 and 4, with good agreement with literature data ^{38,39}. Numbers without errors have been kept constant to their crystallographic value during the fitting procedure. This has been done in order to keep at minimum the correlations between fitting parameters during the EXAFS analysis. For the EXAFS fittings, the V₂O₅ and AIVO₄ spectra, considered as standard materials, have been fitted keeping the distances fixed to their crystallographic values. This gives a value for the E_0 and *amp* parameters that can be considered transferable to the spectra of the samples. This has been done in order to keep at a minimum the number of fitting parameters, avoiding unnecessary correlations.

For the V_2O_5 -like catalysts some examples of fitting results are reported in Fig. 6.

In the V₂O₅ crystal structure, each V is surrounded by 5 oxygen atoms in a distorted square pyramidal coordination (Nearest Neighbour (NN) shell). A further oxygen ion is found at *ca*. 2.7 Å. The Next Nearest Neighbour (NNN) shell is made up by 2 vanadium atoms located at *ca*. 3.1 Å. Further three V atoms are found at *ca*. 3.5 Å. This picture may be formally represented as in Fig. 7*a*. The nearest oxygen may be described as a doubly bonded oxygen (label 1 in Fig. 7*a*-*c*), also according to literature data ³⁹. In addition, three near (< 2Å) and two far (> 2Å) oxygen atoms are found (labels 2,3 and 4,5, respectively, in Fig. 7*a*,*b*). It should be underlined that the oxygen atoms surrounding V and depicted as bound to the photoabsorber, may be only interacting with it in some way, not necessarily by more or less covalent bonds. The V-O distances reported in Table 3 are in fairly good agreement with those reported in ³⁸ and could be interpreted also on the basis of the proposed "umbrella-type" VO_x clusters ^{38,40-42}.

The local structure typical of V_2O_5 , though more or less distorted, characterised all the samples prepared by impregnation or by FP at high V loading, as well as those prepared

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by co-gelation, even at the lowest V concentration (6.7 wt%). The oxygen distance was a bit different for sample V50Si and V50AI, more likely represented as in Fig. 7*c*.

A different structure characterised the so-called AIVO₄-like samples (Fig. 7*d*,*e*). Indeed, no V ions can be inferred nearby the photoabsorber. Furthermore, in the AI containing samples some AI can be found around V. In addition, the V site is surrounded by oxygen atoms in a more ordered array than the V_2O_5 -like samples.

Another very interesting feature is the much lower V-O distance determined for the silica supported V10Si sample with respect to V10Al. This feature may be related to a stronger V-O interaction, which in principle should hinder oxygen release from the catalyst, so decreasing reactants conversion, but eventually improving selectivity towards propylene. Something similar has been already observed by means of EPR analysis ¹⁴⁻¹⁶, though in such case referring to V(IV) ions, only.

It should be remarked that no definite correlation has been so far established on the relationship between vanadyl oxygen and activity/selectivity ⁴³. For instance, a short, terminal V=O bond has been proposed ⁴⁴ for hydrogen abstraction from C-H bond, whereas V-O-V oxygen bridges participate in the next steps when water is formed. By contrast, Kung *et al.* ⁴⁵ proposed the terminal vanadyl bond as responsible for total oxidation and the bridged oxygen atoms as selective sites for propene. Alternatively, it was also proposed that V-O bonds in tetrahedral or octahedral coordination are responsible for selective oxidation, whereas the V-O bonds near a vanadyl oxygen lead to oxygenate products ⁴⁶. V=O bond strength has been correlated with activity in ODH reactions ¹³, but this results has been explicitly criticised by Wachs *et al.* on the basis of a probe methanol ODH reaction ⁴⁷, excluding any direct influence of V=O bond length or strength in ODH performance.

In this confusing panorama, the present findings seem to support and generalise a correlation between the V^{n+} -O bond length (*i.e.* strength) and catalyst selectivity.

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Furthermore, it is in line with very recent DFT calculations ⁴⁸ on propane ODH over a model V₂O₅(001) surface, which definitely confirm the role of the vanadyl oxygen in the reaction ^{49,50}, particularly for the consecutive oxidation of propene ⁴⁸. By contrast higher selectivity is predicted when the oxidant is a bridging oxygen. Increasing reactivity in the case of bridging oxygens was also observed by Lacheen and Iglesia ⁵¹. Also, increasing V=O bond strength has been reported ¹⁸ with increasing the polymerization degree of vanadium over alumina support for catalysts used in the ODH of ethane.

3.5 – Catalyst acidity as studied by means of IR spectroscopy

A thorough IR spectroscopy study of the present catalysts was reported elsewhere ^{14,15}: in summary, different OH species were detected at the surface of V10Si, namely isolated SiOH, H-bonded SiOH and V-OH. Such hydroxyls were characterized by different acidic strength in the order: isolated SiOH < H-bonded SiOH <<V-OH. Their acidic strength was measured by the shift of the OH stretch band after CO adsorption at -196°C (Δv), the larger the shift the larger the acidity of the Brønsted site ⁵².

Another possible means to assess the surface acidity is adsorption of ammonia: the interaction with NH₃ being stronger than with CO, adsorption measurements may be run at r.t. Ammonia molecules may interact with both Lewis acidic sites, by forming acid-base adducts, and Brønsted sites, with formation of ammonium species, characterized by distinct spectroscopic features. In particular, the free ammonium ion is characterized by a band at 1410 cm⁻¹ due to its bending vibration ⁵³. Fig. 8 reports difference spectra recorded after dosing *ca*. 0.4 mbar NH₃ at r.t. on the samples outgassed at 150 °C: the band at 1608 cm⁻¹ is assigned to ammonia molecules coordinated to surface vanadium ions performing as Lewis acidic sites; the band at lower wavenumbers is assigned to the bending vibration of ammonia with Brønsted

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hydroxyls. The position of the latter band changes from sample to sample: with V10Si it is seen at 1448 cm⁻¹, whereas it is red-shifted at higher vanadium loadings, that is when V_2O_5 is present. Fig. 9 reports a chart in which the Δv measured by CO adsorption ¹⁴, which is an actual measure of acidity according to the literature ⁵², is reported as a function of the position of the ammonium band: interestingly, a linear correlation is found. Therefore, it is possible to infer that in V10Si, in which high vanadium dispersion is obtained, weaker acidic sites are present, with respect to the other samples, were V_2O_5 was also present. The same experiment was run with V/AI samples, and the corresponding spectra are reported in Fig. 10: the features of ammonia interacting with Lewis and Brønsted sites are seen at 1613 and 1426-1422 cm⁻¹, respectively. For this set of samples, however, it was not possible to make an analogous discussion on the role of V-sites acidity and its correlation with selectivity (*vide infra*), due to the fact that the Al₂O₃ support itself contains both Lewis and Brønsted sites, hardly distinguishable from those due to vanadium. However, it may be inferred that also the acidic properties of the support may play a role on catalytic activity, as already discussed elsewhere ^{18,54}.

3.6 – Correlation with activity data.

As pointed out in the Introduction, selectivity is one of the key-points for ODH reaction and every factor decreasing full propene oxidation may help to increase such parameter. When looking at the catalytic performance of these samples, a different behaviour was observed depending on the reaction mode ¹⁴⁻¹⁶.

Under aerobic conditions (co-feed mode), propane conversion rate increased as expected with reaction temperature (Fig. 11*a*), but the effect of temperature was much more evident for silica-supported samples than for the alumina based ones, which showed significant propane conversion even at 400 $^{\circ}$ C. Furthermore, for the latter oxygen conversion was full

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at the lowest testing temperature, inducing limited variation of conversion with increasing temperature. Propane conversion rate normalised per g of V decreased with increasing V loading and showed very similar for both supports, irrespectively for the preparation method. In the overall temperature range, high V loading corresponded to depressed selectivity to propylene, the catalyst being predominantly active for full oxidation ¹⁴⁻¹⁶. The productivity of propylene is reported in Fig. 11*b*. It was higher for the alumina supported samples at low temperature, resulted driven by the higher propane conversion, but at the highest testing temperature the higher selectivity to propylene of the silica supported samples allowed to reach higher productivities. The latter parameter was quite independent on V loading, since the data were normalised on V mass, and on the preparation method.

Therefore it may be inferred from the present data that a higher V dispersion, *i.e.* its incorporation and stabilisation into the support matrix, leads to an increase of selectivity to propylene under cofeed conditions, especially at low operating temperature. The reason can be ascribed to the formation of monovanadate species stabilised by the incorporation of V into the support during catalyst preparation. This result confirms the known importance of V site-isolation in improving selectivity for the ODH reaction ^{2,3,18,24,54-58}.

When testing catalyst activity in redox mode, the fully oxidised catalyst was fed with pure propane at fixed temperature (*e.g.* at $550 \,^{\circ}$ C) for 15 minutes. Propane conversion progressively decreased with time-on-stream due to oxygen depletion from the catalyst and contemporarily propylene selectivity increased ¹⁴⁻¹⁶. However, the most interesting points to characterise the performance refer to activity of the fully oxidised catalysts, as reported in Fig.12. Propane conversion rate (Fig. 12*a*) decreased with increasing V loading irrespectively of the support and preparation procedure, whereas it was higher for samples prepared by co-gelation, followed by impregnation and last by the FP ones.

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As for propylene productivity under anaerobic conditions (Fig. 12*b*), it decreased markedly with increasing V loading, indicating a very poor selectivity to propylene at the highest V content. Samples prepared by impregnation demonstrated lower selectivity, thus giving lower propylene productivity than the FP homologues, in spite of their higher conversion rate. Again, samples prepared by co-gelation exhibited the highest productivity, essentially determined by their higher conversion rate.

In principle, co-gelation could induce similarly high V dispersion than FP. However, the present EXAFS data assess the presence of V_2O_5 even for sample VAG1, characterised by much lower V loading than V10Si. Isolated monovanadate species have been also evidenced by Raman spectroscopy for sample VAG1 only, V_2O_5 characterising sample VAG3 ^{30,59}. A deeper investigation of the nature of V_2O_5 aggregates in VAG1 allowed to conclude that they were not exposed on catalyst surface, but embedded into the support matrix and scarcely available for the reactants. Accordingly, much higher selectivity at isoconversion has been already reported for sample VAG1 than for VAG3 ^{30,59}. Therefore, we may further conclude that the best results in terms of selectivity could be reached when site isolation was successfully reached by proper preparation procedure.

Interestingly, a preparation procedure similar to the FP one here proposed, has been suggested also by some other authors ⁶⁰. They substantially agree on the validity of this preparation method to achieve high V dispersion. In such case the mechanism of particle formation was different from ours, due to the employment of different precursors, solvents and pressure drop across the nozzle. Surface area as high as 300 m² g⁻¹ has been reported for different FSP-made V/SiO₂ samples. Anyway, in spite of the much higher surface area of such samples, it is worth noticing that monovanadate species mainly constituted samples with V loading lower than 20 wt%, while V₂O₅ was observed over 25 V wt% as in the present case, in spite of the lower specific surface area of the present samples. However, Schimmoeller *et al.* ⁶⁰ propose a picture of VO_x species fully exposed

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on support surface and deny the hypothesis that vanadium incorporation into the support matrix may somehow occur. The present XAS data seem in contrast with such statement, demonstrating that AIVO₄-like samples, *i.e.* with V incorporation into the support, may exist also with the silica support, provided that the V loading is not too high. The substantial similarity among the two sets of catalysts, the present ones and those reported in ref. 60, is also testified by their catalytic activity. Though the activity tests have been collected under different reaction conditions and in co-feed mode only, the conversion and selectivity trend with respect to temperature and V loading is similar to the data already reported by us ¹⁴. Unfortunately, a rigorous comparison of results is complex, since their data were collected at very different contact time than in the present case. Roughly, the productivity of propylene at 550 °C over the present V10Si sample was 0.2 kg/h kg_{cat}, *i.e.* one order of magnitude lower than that of a similar catalyst (1.2 kg/h kg_{cat}) reported in ⁶⁰. Such difference is fully explainable on the basis of the much lower contact time used by them. Indeed, when increasing contact time they observed a rapid drop of selectivity which brings their results fairly near to the present ones.

A direct influence of V dispersion on catalyst acidity also appears from the data here reported, different for the silica or alumina supported samples. Surface acidity diminished with increasing V dispersion for the V-Si series, while increased for the V-AI ones.

This may be related to the local structure hypothesised for both AIVO₄-like samples, characterised by high V dispersion, which may lead to the formation of different acid sites, which tentative picture is reported in Fig. 13. For catalyst V10Si, OH surface sites form in very high concentration, as confirmed by FTIR analysis ¹⁴, and they were characterised by low acidity, so improving selectivity to propylene. Fig. 14 reports selectivity to propene at iso-conversion (12 % \pm 1) under anaerobic conditions (550 °C) and different times on stream: it decreased in the series V10Si > V28Si > V50Si > V10Si-i, with a tight

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relationship with dispersion and acidity. Higher selectivity was obtained with the sample containing highly dispersed vanadium sites and showing the lowest acidity, as well. By contrast, in the case of V10AI the acid site nature was found much more similar to those found in zeolites, so impressively more acidic than the silica based ones, further explaining the lower selectivity of alumina based sample, irrespectively of V concentration. This point does not represent a real problem when cofeeding propane and oxygen, since acidity is mainly related to catalyst coking. Indeed, olefins may polymerise over acid sites leasing to coke deposition and the addition of oxygen in the feed may help in cleaning the surface.

Finally, the here reported correlations between V oxidation state and surface acidity and selectivity seem to conflict with the conclusions reported in a previous work by Tian *et al.*⁸, where it is stated that the catalytic TOF for propane ODH to propene, which only requires one surface VO₄ unit, is independent of the extent of polymerization of the surface VO₄ species, the E_g value, the surface Brønsted acidity, and the reducibility of the surface vanadia species, and is only a function of the specific oxide support.

Finally, from the XPS compositional analysis, an average oxidation state of vanadium was calculated (last column in Table 2), showing that the average BE of vanadium was higher in the sample with the best catalytic performances (V10Si). In Fig. 15, the values of selectivity to propene in Fig. 14 are reported as a function of the average BE values in Table 2: interestingly, a linear correlation is found showing that, for a homogeneous series of samples supported over SiO₂, selectivity increases with the average vanadium oxidation state, which may also mean a harder reducibility of the active site. Such iso-conversion values were reached after different times-on-stream, so in principle at different oxidation state of V in different materials. In order to elucidate this latter point, Fig. 15 also reports the initial selectivity (time-on-stream = 1 min) under anaerobic conditions and T = 550 °C for V10Si (14% conversion) and V10Si-i (16% conversion), *i.e.* the two samples which

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have the same V content. It is interesting to notice that for V10Si, the two measured values were very similar, in that the selectivity did not change much, whereas the initial selectivity with V10Si-i was lower, as previously reported [14], and increased much with time. In conclusion, it appears that site isolation helps improving the selectivity to propylene. This may be correlated to vanadium oxide reducibility and acidity, at least in the case of silica-supported samples.

The present data insert in the complex panorama sketched in Table 5, where some of the literature reports on the nature and role of active sites for this application are summarized.

4 – CONCLUSIONS

A possible correlation between the local structure of the V active sites and activity and selectivity for propane ODH has been proposed. Dispersed monovanadate species seem the most selective to propylene, but such high dispersion is hardly achieved with traditional preparation methods, except when very low V amount is used. The main drawback of the latter approach is that a decrease of V loading introduces a dependence of selectivity by different factors, such as support nature and acidity.

The proposed flame pyrolysis method for the preparation of silica and alumina supported V-based catalysts allows to attain very high vanadium dispersion at relatively high loading, as demonstrated by the present XAS and TEM analyses, with respect to other methods, such as impregnation or co-gelation. V dispersion showed also an interesting correlation with surface acidity and V oxidation state, at least for the silica-supported samples, which in turn may explain the observed selectivity trend. Finally, the possible structure of V active sites has been proposed on the basis of the refinement of EXAFS data.

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TABLES

Table 1: Catalysts composition and main physical chemical properties.

Sample	Preparation	V loading (wt%)	SSA (m²/g)	XRD phases ³¹
AIVO ₄ ^a	FP	35.9	21	AIVO ₄
V10Si	FP	10.0	75	A ^c
V10Si-i	Impregnation ^b	10.0	-	$A + V_2O_5$
V10AI	FP	10.0	19	δ or η-Al ₂ O ₃
V10Al-i	Impregnation ^b	10.0	-	δ or η-Al ₂ O ₃ + V ₂ O ₅
V28Si	FP	28.4	80	$A + V_2O_5$
V50Si	FP	50.0	46	$A + V_2O_5$
V50AI	FP	50.0	27	δ or η-Al ₂ O ₃ + V ₂ O ₅
VAG1	Co-gel	6.7	490	$A + V_2O_5$
VAG3	Co-gel	15.0	240	$A + V_2O_5$

^a Calcined in air after FP preparation at 600 °C for 1 h

^b On FP-prepared supports

 $^{c}A = Amorphous$

Table 2: Results of curve-fittings on V_{2p 3/2} peaks in XP spectra of V/SiO₂ samples: maximum position (eV) is reported along with the corresponding atomic percentage for V³⁺, V⁴⁺ and V⁵⁺ species. In the last column, weighted average values of Binding Energy (BE) are reported, as calculated by taking into account both maximum position and atomic percentage.

Sample	V ³⁺	V ³⁺	V ⁴⁺	V ⁴⁺	V ⁵⁺	V ⁵⁺	Average
•	(% atom)	BE (eV)	(% atom)	BE (eV)	(% atom)	BE (eV)	BE (eV)
V10Si	15.44	516.3(6)	43.79	517.6(6)	40.77	519.0(3)	518.0(2)
V10Si-i	32.77	516.0(9)	60.35	517.4(1)	6.88	518.7(1)	517.0(7)
V28Si	16.23	516.2(0)	58.93	517.4(6)	24.93	518.2(9)	517.9(3)
V50Si	9.05	516.2(9)	73.74	517.1(7)	17.21	518.5(2)	517.7(2)

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V2O5 V-Oc 2.0174 0.01(2) 1 V-Ov 2.7927 0(6) 1 V-V 3.0818 0.01(1) 2 V-V 3.564 0.01(1) 3 V-Ov 1.5759 0.003(5) 1 V-Oc 1.8775 0.009(7) 2 V-Oc 2.0174 0.01(2) 1 V-Oc 1.3875 0.009(7) 2 V-V 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V10Si-i V-Ov 1.58(7) 0.001(6) 1 V-Oc 2.18731 0.01(5) 2 1 V-Ov 2.8957 0.003(3) 1 1		V-Oc	1.8775	0.008(8)	2	
V-Ov 2.7927 0(6) 1 V-V 3.0818 0.01(1) 2 V-V 3.564 0.01(1) 3 V-Ov 1.5759 0.003(5) 1 V-Ob 1.7785 0.01(2) 1 V-Oc 1.8775 0.009(7) 2 V-Oc 2.0174 0.01(2) 1 V-Ov 2.7927 0.441 1 V-Ov 2.7927 0.441 1 V-Ov 3.13(5) 0.007(7) 2 V-V 3.13(5) 0.001(6) 1 V-Ov 1.58(7) 0.001(6) 1 V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 2.8957 0.00(3) 1 V-Oc 2.8957 0.00(2) 1 V-Ov 3.4(1) 0.02(1) 3 V-V 3.4(1) 0.016(7) 1 V-Ov 1.8775 0.016(7) 1 V-Oc 2.7927	V_2O_5	V-Oc	2.0174	0.01(2)	1	
V-V 3.0818 0.01(1) 2 V-V 3.564 0.01(1) 3 V-V 3.564 0.01(1) 3 V-Ov 1.5759 0.003(5) 1 V-Oc 1.8775 0.009(7) 2 V-Oc 2.0174 0.01(2) 1 V-Ov 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Oc 1.8731 0.01(5) 1 V-Oc 1.8731 0.01(6) 1 V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-V 3.4(1) 0.016(7) 1 V-Ov 1.59(3) 0.007(4) 1 V-Ov 2.0174 0.016(7)		V-Ov	2.7927	0(6)	1	
V-V 3.564 0.01(1) 3 V-Ov 1.5759 0.003(5) 1 V-Ob 1.7785 0.01(2) 1 V-Oc 1.8775 0.009(7) 2 V-Oc 2.0174 0.01(2) 1 V-Ov 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Oc 1.8731 0.01(5) 2 V-Oc 1.8731 0.01(5) 2 V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-V 3.4(1) 0.02(1) 3 V28Si V-Ov 1.59(3) 0.007(4) 1 V-Oc 1.8775		V-V	3.0818	0.01(1)	2	
V-Ov 1.5759 0.003(5) 1 V-Ob 1.7785 0.01(2) 1 V-Oc 1.8775 0.009(7) 2 V-Oc 2.0174 0.01(2) 1 V-Oc 2.0174 0.01(2) 1 V-Ov 2.7927 0.441 1 V-V 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Oc 1.8731 0.01(6) 1 V-Oc 2.1264 0.00(2) 1 V-Oc 2.8957 0.00(3) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 3.13(7) 0.01(1) 2 V-V 3.4(1) 0.02(1) 3 V28Si V-Ov 1.59(3) 0.007(4) 1 V-Oc 1.8775 0.016(7) 2 V28Si V-Oc 1.8775 0.016(7) 1 V-Oc		V-V	3.564	0.01(1)	3	
V-Ov 1.5759 0.003(5) 1 V-Ob 1.7785 0.01(2) 1 V-Oc 1.8775 0.009(7) 2 V-Oc 2.0174 0.01(2) 1 V-Oc 2.0174 0.01(2) 1 V-Ov 2.7927 0.441 1 V-V 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Oc 1.58(7) 0.001(6) 1 V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 2.8957 0.00(3) 1 V-Ov 2.8957 0.00(3) 1 1 V-Ov 2.8957 0.00(3) 1 1 V-Ov 1.59(3) 0.007(4) 1 1 V-Ov 1.59(3) 0.007(4) 1 1 V-Ov 1.8(1) 0.016(7) 1 1 V-Ov 1.8775 0.016(7) 1 1 V-Ov <td< td=""><td></td><td></td><td></td><td></td><td></td></td<>						
V-Ob 1.7785 0.01(2) 1 V-Oc 1.8775 0.009(7) 2 V-Oc 2.0174 0.01(2) 1 V-Oc 2.0174 0.01(2) 1 V-Oc 2.0174 0.01(2) 1 V-Ov 2.7927 0.441 1 V-V 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Ov 1.58(7) 0.001(6) 1 V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 2.1264 0.00(2) 1 V-Oc 2.8957 0.00(3) 1 V-Ov 2.8957 0.00(3) 1 V-V 3.4(1) 0.02(1) 3 V28Si V-Ov 1.59(3) 0.007(4) 1 V-Oc 1.8775 0.016(7) 1 V-Oc 1.8775 0.016(7) 1 V-Oc 1.8775 0.016(7) 1 V-Ov </td <td></td> <td>V-Ov</td> <td>1.5759</td> <td>0.003(5)</td> <td>1</td>		V-Ov	1.5759	0.003(5)	1	
V10Al-i V-Oc 1.8775 0.009(7) 2 V10Al-i V-Oc 2.0174 0.01(2) 1 V-Ov 2.7927 0.441 1 V-V 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Oc 1.58(7) 0.001(6) 1 V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 3.4(1) 0.02(1) 3 V-V 3.4(1) 0.02(1) 3 V28Si V-Ov 1.59(3) 0.007(4) 1 V-Ov 1.8775 0.016(7) 1 V-Ov 2.7927 0.431 1 V-Ov 2.7927 0.431 1 V-Ov <td< td=""><td></td><td>V-Ob</td><td>1.7785</td><td>0.01(2)</td><td>1</td></td<>		V-Ob	1.7785	0.01(2)	1	
V10Al-i V-Oc 2.0174 0.01(2) 1 V-Ov 2.7927 0.441 1 V-V 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Ov 1.58(7) 0.001(6) 1 V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 1.8731 0.01(5) 2 V-Oc 1.8731 0.01(1) 2 2 V-Oc 1.8731 0.01(1) 2 1 V-Oc 2.8957 0.00(3) 1 2 V-V 3.4(1) 0.02(1) 3 3 V-V 3.4(1) 0.002(1) 3 3 V-Ov 1.59(3) 0.007(4) 1 V-Oc 1.8775 0.016(7) 1 V-Oc 1.8775 0.016(7) 1 V-Ov 2.7927 0.431 1 V-Ov 2.7927 0.431 1 V-Ov 1.		V-Oc	1.8775	0.009(7)	2	
V-Ov 2.7927 0.441 1 V-V 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Ov 1.58(7) 0.001(6) 1 V-Ob 1.881) 0.00(3) 1 V-Oc 1.8731 0.01(5) 2 V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 3.13(7) 0.01(1) 2 V-V 3.4(1) 0.02(1) 3 V-V 3.4(1) 0.016(7) 1 V-Ov 1.59(3) 0.007(4) 1 V-Oc 1.8775 0.016(7) 2 V28Si V-Oc 2.0174 0.016(7) 1 V-Ov 2.7927 0.431 1 V-Ov 2.7927 0.431 1 V-Ov 1.5(1) 0.023 1 V-Oc 1.93(6)	V10Al-i	V-Oc	2.0174	0.01(2)	1	
V-V 3.13(5) 0.007(7) 2 V-V 3.494(9) 0.02(1) 3 V-Ov 1.58(7) 0.001(6) 1 V-Ob 1.881) 0.00(3) 1 V-Oc 1.8731 0.01(5) 2 V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 3.13(7) 0.01(1) 2 V-V 3.4(1) 0.02(1) 3 V-Ov 1.59(3) 0.007(4) 1 V-Oc 1.8775 0.016(7) 2 V28Si V-Oc 2.0174 0.016(7) 1 V-Ov 2.7927 0.431 1 V-Ov 2.7927 0.431 1 V-Ov 1.5(1) 0.023 1 V-Ov 1.8274 0.005(5) 2 V-Oc 1.8274		V-Ov	2.7927	0.441	1	
V-V 3.494(9) 0.02(1) 3 V-Ov 1.58(7) 0.001(6) 1 V-Ob 1.881) 0.00(3) 1 V-Oc 1.8731 0.01(5) 2 V-Oc 2.1264 0.00(2) 1 V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-V 3.13(7) 0.01(1) 2 V-V 3.4(1) 0.02(1) 3 V-V 3.4(1) 0.02(1) 3 V28Si V-Ov 1.59(3) 0.007(4) 1 V-Ob 1.8(1) 0.016(7) 1 V-Oc 1.8775 0.016(7) 2 V28Si V-Oc 2.0174 0.016(7) 1 V-Ov 2.7927 0.431 1 V-Ov 3.06(5) 0.014(6) 2 V-V 3.4(2) 0.04(3) 3 V-Oc 1.8274 0.005(5) 1 V-Oc		V-V	3.13(5)	0.007(7)	2	
V-Ov 1.58(7) 0.001(6) 1 V-Ob 1.881) 0.00(3) 1 V-Oc 1.8731 0.01(5) 2 V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-Ov 2.8957 0.00(3) 1 V-V 3.13(7) 0.01(1) 2 V-V 3.4(1) 0.02(1) 3 V-V 3.4(1) 0.016(7) 1 V-Oc 1.8775 0.016(7) 2 V28Si V-Oc 2.0174 0.016(7) 1 V-Oc 1.8775 0.016(7) 1 1 V-Ov 2.7927 0.431 1 1 V-Ov 2.7927 0.431 1 1 V-V 3.06(5) 0.002 1 1 V-Ov 1.5(1) 0.023 1 1 V-Ov 1.8274 0.005(5) 2 1 V-Oc 1.8274		V-V	3.494(9)	0.02(1)	3	
V-Ov 1.58(7) 0.001(6) 1 V-Ob 1.881) 0.00(3) 1 V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-V 3.13(7) 0.01(1) 2 V-V 3.4(1) 0.02(1) 3 V-V 3.4(1) 0.016(7) 1 V-Oc 1.8775 0.016(7) 1 V-Oc 1.8775 0.016(7) 1 V-Oc 2.0174 0.016(7) 1 V-Oc 2.0174 0.016(7) 1 V-Ov 2.7927 0.431 1 V-Ov 2.7927 0.431 1 V-V 3.06(5) 0.014(6) 2 V-V 3.4(2) 0.04(3) 3 V-Oc 1.8274 0.005(5) 1 V-Oc 1.8274 0.005(5) 1 V-Ov 2.8047						
V-Ob 1.881) 0.00(3) 1 V-Oc 1.8731 0.01(5) 2 V10Si-i V-Oc 2.1264 0.00(2) 1 V-Ov 2.8957 0.00(3) 1 V-V 3.13(7) 0.01(1) 2 V-V 3.4(1) 0.02(1) 3 V-V 3.4(1) 0.016(7) 1 V-Oc 1.8775 0.016(7) 1 V-Oc 1.8775 0.016(7) 1 V-Oc 2.0174 0.016(7) 1 V-Ov 2.7927 0.431 1 V-Ov 2.7927 0.431 1 V-V 3.06(5) 0.014(6) 2 V-V 3.4(2) 0.04(3) 3 V50Al V-Oc 1.8274 0.005(5) 2 V50Al V-Oc 1.8274 0.005(5) 1 V-Oc 1.8274 0.004(3) 3 V50Si V-Ov 1.6(1) 0.02(3) 3 <td></td> <td>V-Ov</td> <td>1.58(7)</td> <td>0.001(6)</td> <td>1</td>		V-Ov	1.58(7)	0.001(6)	1	
$V10Si-i = V-Oc = 1.8731 = 0.01(5) = 2 \\ V-Oc = 2.1264 = 0.00(2) = 1 \\ V-Ov = 2.8957 = 0.00(3) = 1 \\ V-V = 3.13(7) = 0.01(1) = 2 \\ V-V = 3.4(1) = 0.02(1) = 3 \\ V-V = 3.4(1) = 0.02(1) = 3 \\ V-V = 3.4(1) = 0.02(1) = 3 \\ V-Oc = 1.8775 = 0.016(7) = 1 \\ V-Oc = 1.8775 = 0.016(7) = 2 \\ V-Oc = 2.0174 = 0.016(7) = 1 \\ V-Ov = 2.8047 = 0.014(6) = 2 \\ V-Ov = 3.4(2) = 0.002(3) = 1 \\ V-Ov = 2.8047 = 0.01(8) = 1 \\ V-Ov = 2.8047 = 0.01(8) = 1 \\ V-V = 3.12(6) = 0.004(7) = 2 \\ V-V = 3.45(3) = 0.02(3) = 3 \\ V50Si = \frac{V-Ov = 1.6(1) = 0.02(5) = 1 \\ V-Oc = 1.7375 = 0.04(7) = 2 \\ V-Oc = 1.8774 = 0.04(7) = 1 \\ \hline \end{array}$		V-Ob	1.881)	0.00(3)	1	
$\begin{array}{ c c c c c c c c c c c c c c c c c c c$		V-Oc	1.8731	0.01(5)	2	
$\begin{array}{ c c c c c c c c c c c c c c c c c c c$	V10Si-i	V-Oc	2.1264	0.00(2)	1	
V-V 3.13(7) 0.01(1) 2 V-V 3.4(1) 0.02(1) 3 V-V 3.4(1) 0.02(1) 3 V-Ov 1.59(3) 0.007(4) 1 V-Ob 1.8(1) 0.016(7) 1 V-Oc 1.8775 0.016(7) 2 V-Oc 2.0174 0.016(7) 1 V-Oc 2.7927 0.431 1 V-Ov 2.7927 0.431 1 V-V 3.06(5) 0.014(6) 2 V-V 3.4(2) 0.04(3) 3 V-Oc 1.93(6) 0.0023 1 V-Oc 1.8274 0.005(5) 2 V-Oc 1.8274 0.005(5) 1 V-Oc 1.8274 0.004(7) 2 V-V 3.12(6) 0.004(7) 2 V-V 3.45(3) 0.02(3) 3 V50Si V-Oc 1.6(1) 0.02(5) 1 V-Oc 1.7375		V-Ov	2.8957	0.00(3)	1	
V-V 3.4(1) 0.02(1) 3 V-Ov 1.59(3) 0.007(4) 1 V-Ob 1.8(1) 0.016(7) 1 V-Oc 1.8775 0.016(7) 2 V-Oc 2.0174 0.016(7) 1 V-Oc 2.0174 0.016(7) 1 V-Ov 2.7927 0.431 1 V-V 3.06(5) 0.014(6) 2 V-V 3.4(2) 0.04(3) 3 V-V 3.4(2) 0.04(3) 3 V-Oc 1.93(6) 0.002(1) 1 V-Oc 1.8274 0.005(5) 2 V-Oc 1.8274 0.005(5) 1 V-Oc 1.8274 0.004(7) 2 V-V 3.12(6) 0.004(7) 2 V-V 3.45(3) 0.02(3) 3 V50Si V-Oc 1.6(1) 0.02(5) 1 V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774 </td <td></td> <td>V-V</td> <td>3.13(7)</td> <td>0.01(1)</td> <td>2</td>		V-V	3.13(7)	0.01(1)	2	
V-Ov 1.59(3) 0.007(4) 1 V-Ob 1.8(1) 0.016(7) 1 V-Oc 1.8775 0.016(7) 2 V-Oc 2.0174 0.016(7) 1 V-Ov 2.7927 0.431 1 V-V 3.06(5) 0.014(6) 2 V-V 3.4(2) 0.04(3) 3 V-V 3.4(2) 0.04(3) 3 V-Ov 1.5(1) 0.023 1 V-Ob 1.66(5) 0.002 1 V-Oc 1.93(6) 0.005(5) 2 V-Oc 1.8274 0.005(5) 1 V-Ov 2.8047 0.01(8) 1 V-Ov 2.8047 0.01(8) 1 V-V 3.12(6) 0.004(7) 2 V-V 3.45(3) 0.02(3) 3 V50Si V-Ov 1.6(1) 0.02(5) 1 V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774		V-V	3.4(1)	0.02(1)	3	
$V28Si = \begin{array}{c ccccccccccccccccccccccccccccccccccc$						
V-Ob 1.8(1) 0.016(7) 1 V-Oc 1.8775 0.016(7) 2 V-Oc 2.0174 0.016(7) 1 V-Ov 2.7927 0.431 1 V-V 3.06(5) 0.014(6) 2 V-V 3.4(2) 0.04(3) 3 V-V 3.4(2) 0.04(3) 3 V-Ov 1.5(1) 0.023 1 V-Ob 1.66(5) 0.002 1 V-Oc 1.93(6) 0.005(5) 2 V50Al V-Oc 1.8274 0.005(5) 1 V-Ov 2.8047 0.01(8) 1 V-V 3.12(6) 0.004(7) 2 V-V 3.45(3) 0.02(3) 3 V50Si V-Ov 1.6(1) 0.02(5) 1 V-Oc 1.7375 0.04(7) 2 V-Oc 1.7375 0.04(7) 1		V-Ov	1.59(3)	0.007(4)	1	
V28SiV-Oc 1.8775 $0.016(7)$ 2 V-Oc 2.0174 $0.016(7)$ 1 V-Ov 2.7927 0.431 1 V-V $3.06(5)$ $0.014(6)$ 2 V-V $3.4(2)$ $0.04(3)$ 3 V-VV-OvV-Ov $1.5(1)$ 0.023 V-Ob $1.66(5)$ 0.002 V-Oc $1.93(6)$ $0.005(5)$ 2 V50AlV-Oc 1.8274 $0.005(5)$ 1 V-Ov 2.8047 $0.01(8)$ 1 V-Ov 2.8047 $0.01(8)$ 1 V-V $3.12(6)$ $0.004(7)$ 2 V-V $3.45(3)$ $0.02(3)$ 3 V-Ov $1.6(1)$ $0.02(5)$ V50Si $V-Oc$ 1.7375 $0.04(7)$ 2 V-Oc 1.8774 $0.04(7)$ 1		V-Ob	1.8(1)	0.016(7)	1	
$V28Si = \frac{V-Oc}{V-Ov} = \frac{2.0174}{0.016(7)} = \frac{1}{1}$ $V-Ov = \frac{2.7927}{0.431} = \frac{1}{1}$ $V-V = \frac{3.06(5)}{0.014(6)} = \frac{2}{2}$ $V-V = \frac{3.4(2)}{0.04(3)} = \frac{1}{3}$ $V-Ov = \frac{1.5(1)}{0.023} = \frac{1}{1}$ $V-Ob = \frac{1.66(5)}{0.002} = \frac{1}{1}$ $V-Oc = \frac{1.93(6)}{0.005(5)} = \frac{1}{2}$ $V50AI = \frac{V-Ov}{1.6(1)} = \frac{1.6(1)}{0.02(3)} = \frac{1}{3}$ $V-Ov = \frac{1.6(1)}{0.02(3)} = \frac{1}{3}$ $V50Si = \frac{V-Ov}{1.6(1)} = \frac{1.6(1)}{0.02(5)} = \frac{1}{1}$ $V-Oc = \frac{1.7375}{0.04(7)} = \frac{1}{2}$ $V-Oc = \frac{1.8774}{0.04(7)} = \frac{1}{1}$	N (22.0)	V-Oc	1.8//5	0.016(7)	2	
$\begin{array}{ c c c c c c c c c c c c c c c c c c c$	V28Si	V-Oc	2.0174	0.016(7)	1	
$\begin{array}{c c c c c c c c c c c c c c c c c c c $		V-Ov	2.7927	0.431	1	
V-V = 3.4(2) = 0.04(3) = 3 $V-V = 1.5(1) = 0.023 = 1$ $V-Ob = 1.66(5) = 0.002 = 1$ $V-Oc = 1.93(6) = 0.005(5) = 2$ $V-Oc = 1.8274 = 0.005(5) = 1$ $V-Ov = 2.8047 = 0.01(8) = 1$ $V-V = 3.12(6) = 0.004(7) = 2$ $V-V = 3.45(3) = 0.02(3) = 3$ $V-Oc = 1.6(1) = 0.02(5) = 1$ $V-Oc = 1.7375 = 0.04(7) = 2$ $V-Oc = 1.8774 = 0.04(7) = 1$		V-V	3.06(5)	0.014(6)	2	
$V50AI = \begin{bmatrix} V-Ov & 1.5(1) & 0.023 & 1 \\ V-Ob & 1.66(5) & 0.002 & 1 \\ V-Oc & 1.93(6) & 0.005(5) & 2 \\ V-Oc & 1.8274 & 0.005(5) & 1 \\ V-Ov & 2.8047 & 0.01(8) & 1 \\ V-V & 3.12(6) & 0.004(7) & 2 \\ V-V & 3.45(3) & 0.02(3) & 3 \\ \end{bmatrix}$		V-V	3.4(2)	0.04(3)	3	
$V50AI = \begin{array}{c ccccccccccccccccccccccccccccccccccc$		V-Ov	1.5(1)	0.023	1	
V50Al V-Oc 1.03(6) 0.001 1 V50Al V-Oc 1.93(6) 0.005(5) 2 V-Oc 1.8274 0.005(5) 1 V-Ov 2.8047 0.01(8) 1 V-V 3.12(6) 0.004(7) 2 V-V 3.45(3) 0.02(3) 3 V-Ov 1.6(1) 0.02(5) 1 V50Si V-Ov 1.6(1) 0.02(5) 1 V50Si V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774 0.04(7) 1		V-Ob	1.66(5)	0.002	1	
$\begin{array}{c ccccccccccccccccccccccccccccccccccc$		V-Oc	1.93(6)	0.005(5)	2	
V-Ov 2.8047 0.01(8) 1 V-V 3.12(6) 0.004(7) 2 V-V 3.45(3) 0.02(3) 3 V50Si V-Ov 1.6(1) 0.02(5) 1 V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774 0.04(7) 1	V50AI	V-Oc	1.8274	0.005(5)	1	
$\begin{array}{c ccccccccccccccccccccccccccccccccccc$		V-Ov	2.8047	0.01(8)	1	
V-V 3.45(3) 0.02(3) 3 V50Si V-Ov 1.6(1) 0.02(5) 1 V-Ob 1.92(5) 0.003(5) 1 V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774 0.04(7) 1		V-V	3.12(6)	0.004(7)	2	
V-Ov 1.6(1) 0.02(5) 1 V50Si V-Ob 1.92(5) 0.003(5) 1 V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774 0.04(7) 1		V-V	3.45(3)	0.02(3)	3	
V-Ov 1.6(1) 0.02(5) 1 V50Si V-Ob 1.92(5) 0.003(5) 1 V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774 0.04(7) 1		ı	\- <u></u> /	\ [−] /_		
V-Ob 1.92(5) 0.003(5) 1 V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774 0.04(7) 1		V-Ov	1.6(1)	0.02(5)	1	
V-Oc 1.7375 0.04(7) 2 V-Oc 1.8774 0.04(7) 1		V-Ob	1.92(5)	0.003(5)	1	
V-Oc 1.8774 0.04(7) 1	V50Si	V-Oc	1.7375	0.04(7)	2	
		V-Oc	1.8774	0.04(7)	1	

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	V-Ov	2.7767	0.01(2)	1
	V-V	3.09(3)	0.008(5)	2
	V-V	3.4(1)	0.01(2)	1
	V-Ov	1.56(3)	0.004(3)	1
	V-Ob	1.7(1)	0.01(1)	1
	V-Oc	1.8775	0.01(1)	2
VAG1	V-Oc	2.0174	0.01(1)	1
	V-Ov	2.7927	0.346	1
	V-V	3.07(3)	0.011(4)	2
	V-V	3.4(1)	0.03(2)	3
	V-Ov	1.5(1)	0.01(2)	1
VAG3	V-Ob	1.7(1)	0.01(2)	1
	V-Oc	2.00(5)	0.003(9)	2
	V-Oc	1.8264	0.003(9)	1
	V-Ov	2.9007	0.001	1
	V-V	3.11(4)	0.009(5)	2
	V-V	3.454	0.02(2)	3

Catalyst	Shell	<i>r</i> (Å)	s²(Å⁻²)	Ν
	V-O(11)	1.7125	0.012(1)	4
	V-O(3)	3.0085	0.001(9)	0.67
AIVO ₄	V-O(10)	3.1500	0.01(1)	0.67
	V-AI(3)	3.1896	0.02(1)	3.33
	V-O(11)	1.78(1)	0.031(3)	4
V10AI	V-O(3)	2.9(1)	0.001	0.67
VIUAI	V-O(10)	3.15000	0.0(1)	0.67
	V-AI(3)	3.4186	0.03(2)	3.33
	V-O(11)	1.56(2)	0.002	1
V10Si	V-O(6)	1.84(4)	0.027(6)	4
	V-O(3)	3.0(1)	0.01(2)	1

Table 4: V local structure from EXAFS data for AIVO₄-like samples.

Table 5: Schematic summary of some literature reports on the nature and role of active sites for the ODH of propane.

Reference	Hypothesis
7	One-electron reduction pathway for isolated vanadyls; two-electrons path
	for dimeric species
6	Two-electrons reduction pathway not excluded for monomeric species
8	Preferential two-electron reduction pathway
10	One-electron pathway active for alumina-supported samples, two- electrons one for silica-based ones
11	One-electron reduction way for both silica and alumina-supported samples
8, here	Polymerisation degree $SiO_2 \ll ZrO_2 \ll Al_2O_3$; isolated species detected only over silica.
38, 40-42	Description of the umbrella-type configuration of the active sites.
Here	Higher dispersion (isolated vanadyls) obtained with flame pyrolysis, particularly over silica; for the latter support increasing dispersion led to lower Brønsted acidity and higher average V oxidation state
14-16	Lower V=O bond length (higher bond strength) for silica-supported samples than for alumina-based ones
14-16, 21-23	V polymerisation increases reaction rate up to monolayer; low selectivity for bulk V_2O_5
44	V=O bond active for H abstraction, V-O-V for water formation
45	V=O active for total oxidation; V-O-V for selective propene formation
46	Higher selectivity for tetrahedral or octahedral V sites
13-16, here	Correlation of V=O strength/length with activity and selectivity to propene
47	No influence of V=O strength/length with activity and selectivity to propene
48	V=O involved in the consecutive oxidation of propene
Here	Increasing dispersion increases selectivity, particularly under anaerobic conditions; for the VO_x/SiO_2 catalysts the increase of selectivity has been also correlated to decreasing Brønsted acidity and higher average V oxidation state

FIGURE CAPTIONS

Fig. 1: SEM analysis of samples V10Si (a), V50Si (b), V10AI (c), V50AI (d). Marker size = 300 nm except for a) = 100 nm.

Fig. 2: TEM analysis: V10Si (a), V28Si (b), V50Si (c,d), V50AI (e).

Fig. 3: TEM-EDX maps of V and Si for sample V10Si (a) and V10AI (b). Marker size: 20 and 50 nm, respectively.

Fig. 4: XPS spectra in the O_{1s} BE range (a) and in the V_{2p} BE range (b). XPS curves were stacked for clarity.

Fig. 5: XANES spectra (a) and the corresponding derivatives (b).

Fig. 6: EXAFS data fitting for the reference V_2O_5 (a) and V50AI (b).

Fig. 7: Tentative picture of V-sites in V_2O_5 -like (a,b,c) and AIVO₄-like (d,e) samples. When relevant, numerical labels refer to increasingly distant oxygen species.

Fig. 8: FT-IR spectra recorded after dosing *ca.* 0.4 mbar on V/SiO₂ samples outgassed at 150 ℃. Difference spectra are reported, as obtained after subtraction of spectra of bare samples.

Fig. 9: Correlation between the position of the band due to the bending vibration of NH_4^+ species (as measured in Fig. 9) and the red-shift of the O-H stretching mode (Δv), as previously measured after CO adsorption at nominal -196 °C ¹⁴.

Fig. 10: FT-IR spectra recorded after dosing *ca.* 0.4 mbar of ammonia on V/Al₂O₃ samples outgassed at 150 °C. Difference spectra are reported, as obtained after subtraction of spectra of bare samples.

Fig. 11: (a) Propane conversion rate at 400 °C (425 °C for samples V10Si-i and V10Al-i) and 525 °C (550 °C for samples V10Si and VAG1) normalised per gram of V; (b) Propylene productivity at 400 °C (425 °C for samples V10Si-i and V10Al-i) and 525 °C (550 °C for samples V10Si-i and V10Al-i) and 525 °C (550 °C for samples V10Si-i and V10Al-i) and 525 °C (550 °C for samples V10Si-i and V10Al-i) and 525 °C (550 °C for samples V10Si-i and V10Al-i) and 525 °C (550 °C for samples V10Si-i and V10Al-i).

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Fig. 12: Propane conversion rate (a) and propylene productivity (b) under redox conditions. Reaction temperature 550 °C; data collected on the fully oxidised sample.

Fig. 13: Possible structure of acid sites in V10Si and V10Al samples.

Fig. 14: Correlation between V site-isolation, acid strength and selectivity to propene under anaerobic reaction conditions at 550 °C. Data collected at $12 \pm 1\%$ conversion.

Fig. 15: Maximum selectivity to propene (%), measured under anaerobic reaction conditions at 550 °C, at 12 ± 1 % conversion, reported as a function of the average BE of the V_{2p 3/2} peak (eV) reported in Table 2.

Fig. 1: SEM analysis of samples V10Si (a), V50Si (b), V10AI (c), V50AI (d). Marker size =

300 nm except for a = 100 nm.

(a)



(b)





Fig. 2: TEM analysis: V10Si (a), V28Si (b), V50Si (c,d), V50Al (e).

(a)







(d)





Fig. 3: TEM-EDX maps of V and Si for sample V10Si (a) and V10AI (b). Marker size: 20 and 50 nm, respectively.

(a)



(b)



Fig. 4: XPS spectra in the O_{1s} BE range (a) and in the V_{2p} BE range (b). XPS curves were stacked for clarity.













(a)





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Fig. 7: Tentative picture of V-sites in V₂O₅-like (a,b,c) and AIVO₄-like (d,e) samples. When relevant, numerical labels refer to increasingly distant oxygen species.





Fig. 8: FT-IR spectra recorded after dosing *ca.* 0.4 mbar on V/SiO₂ samples outgassed at 150 °C. Difference spectra are reported, as obtained after subtraction of spectra of bare samples.



Fig. 9: Correlation between the position of the band due to the bending vibration of NH_4^+ species (as measured in Fig. 9) and the red-shift of the O-H stretching mode (Δv), as previously measured after CO adsorption at nominal -196 °C ¹⁴.

Fig. 10: FT-IR spectra recorded after dosing *ca.* 0.4 mbar of ammonia on V/Al_2O_3 samples outgassed at 150 °C. Difference spectra are reported, as obtained after subtraction of spectra of bare samples.

Fig. 11: (a) Propane conversion rate at 400 °C (425 °C for samples V10Si-i and V10Al-i) and 525 °C (550 °C for samples V10Si and VAG1) normalised per gram of V; (b) Propylene productivity at 400 °C (425 °C for samples V10Si-i and V10Al-i) and 525 °C (550 °C for samples V10Si and VAG1) normalised per mass of V. Data collected under aerobic conditions.

(a)

Fig. 12: Propane conversion rate (a) and propylene productivity (b) under anaerobic conditions. Reaction temperature 550 °C; data collected on the fully oxidised sample.

Fig. 14: Correlation between V site-isolation, acid strength and selectivity to under anaerobic reaction conditions at 12 ± 1 % iso-conversion (reaction temperature 550 °C).

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Fig. 15: Black squares: values of selectivity to propene (%), measured under anaerobic reaction conditions at 550 °C and at 12 ± 1 % iso-conversion, reported as a function of the average BE of the V_{2p 3/2} peak (eV) reported in Table 2. White circles: values of initial selectivity to propene (%) measured after 1 min-on-stream (*) with V10Si and V10Si-i samples.

